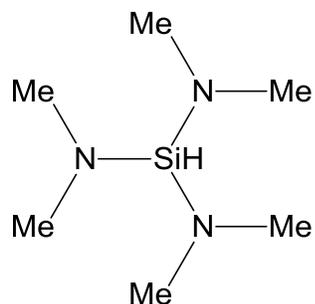




Catalog # T281800 Tris(dimethylamino)silane



Technical Notes:

1. Silicon precursor for the atomic layer deposition (ALD) and CVD of silicon containing thin films.

References:

1. *Nanoscale Research Letters*, **2017**, 12, 370.
2. *Journal of the Korean Physical Society*, **2015**, 67(12), 2115.
3. *Journal of Materials Science: Materials in Electronics*, **2012**, 23, 2075.